

#2  
Pre Amended  
A  
RABEED  
7/1/01

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re New Patent Application of )  
Koichiro TANAKA )  
Japanese Priority Application 2000-024615 ) Attn: Applications  
Japanese Priority Date: February 2, 2000 ) Branch  
For: BEAM HOMOGENIZER, LASER )  
IRRADIATION APPARATUS, )  
SEMICONDUCTOR DEVICE, AND )  
METHOD OF FABRICATING THE )  
SEMICONDUCTOR DEVICE ) Date: February 1, 2001

PRELIMINARY AMENDMENT

Honorable Assistant Commissioner for Patents  
Washington, D.C. 20231

Sir:

Please preliminarily amend the subject application as follows:

IN THE SPECIFICATION:

Page 18, line 16, change "Figs. 13A and 13B" to --Figs. 13A, 13B and 13C--.

REMARKS

This application has been amended to correct the brief description of Figure  
13.